



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the Application of:

FRANK LEONARD SCHADT, III

CASE NO.: PE0612 US PCT

APPLICATION NO.: 09/807,298

GROUP ART UNIT: UNKNOWN

FILED: APRIL 9, 2001

EXAMINER: UNKNOWN

FOR: PHOTORESISTS AND PROCESSES FOR
MICROLITHOGRAPHY

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

Prior to examination of the above-referenced application, Applicants request entry of the amendment detailed below.

IN THE CLAIMS:

Please add the following new claims:

30. (NEW) The photoresist of Claim 10 wherein the solvent is selected from the group consisting of cyclohexanone, 2-butanone, propylene glycol methyl ether acetate, and methyl isobutyl ketone.
31. (NEW) The photoresist of Claim 10 wherein the solvent is selected from the group consisting of (i) 2-butanone and propylene glycol methyl ether acetate in combination, (ii) methyl isobutyl ketone and propylene glycol methyl ether acetate in combination, and (iii) cyclohexanone and propylene glycol methyl ether acetate in combination.
32. (NEW) The process of Claim 27 wherein the solvent is selected from the group consisting of cyclohexanone, 2-butanone, propylene glycol methyl ether acetate, and methyl isobutyl ketone.
33. (NEW) The process of Claim 27 wherein the solvent is selected from the group consisting of (i) 2-butanone and propylene glycol methyl ether acetate in combination, (ii) methyl isobutyl ketone and propylene glycol methyl ether acetate in combination, and (iii) cyclohexanone and propylene glycol methyl ether acetate in combination.

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